

119TH CONGRESS
1ST SESSION

H. R. 5287

To require an annual report on the advanced semiconductor manufacturing capabilities of the People's Republic of China.

IN THE HOUSE OF REPRESENTATIVES

SEPTEMBER 10, 2025

Mr. VINDMAN (for himself and Mr. MOYLAN) introduced the following bill;
which was referred to the Committee on Foreign Affairs

A BILL

To require an annual report on the advanced semiconductor manufacturing capabilities of the People's Republic of China.

1 *Be it enacted by the Senate and House of Representa-*
2 *tives of the United States of America in Congress assembled,*

3 **SECTION 1. SHORT TITLE.**

4 This Act may be cited as the “China Advanced Tech-
5 nology Monitoring Act”.

6 **SEC. 2. ANNUAL REPORT ON ADVANCED SEMICONDUCTOR**
7 **MANUFACTURING CAPABILITIES OF CHINA.**

8 (a) REPORT.—Not later than May 1, 2026, and an-
9 nually thereafter for 5 years, the Secretary of Defense,
10 in consultation with the heads other Federal departments

1 and agencies as appropriate, shall submit to the Commit-
2 tees on Armed Services of the House of Representatives
3 and the Senate a report on the semiconductor manufac-
4 turing capabilities, including advanced and mature-node
5 semiconductors, of the People's Republic of China.

6 (b) ELEMENTS.—The report required by subsection
7 (a) shall also include the following:

8 (1) A statement of key findings and assess-
9 ments with respect to the United States strategy to
10 counter China and specific policy recommendations
11 to Congress regarding China's goal to advance semi-
12 conductor manufacturing.

13 (2) An assessment of the domestic semicon-
14 ductor manufacturing capabilities of China.

15 (3) A detailed analysis of the industrial policies
16 of China and the outcomes of such policies on such
17 manufacturing capabilities.

18 (4) A year-by-year assessment of technological
19 development efforts by China in the fields of semi-
20 conductor manufacturing and artificial intelligence
21 chipmaking, including relevant government plans
22 and initiatives, that specifically addresses gains in
23 every aspect of manufacturing, such as design, intel-
24 lectual property, research and development, silicon
25 and critical minerals, industrial gases, intermediaries

1 such as photomasks, equipment, tools, and software,
2 and advanced packaging techniques.

3 (5) A description of engagement between China
4 and other foreign countries with respect to semicon-
5 ductor manufacturing equipment capabilities, includ-
6 ing—

7 (A) coordination with other countries and
8 markets to expand semiconductor influence; and

9 (B) foreign investment, trade, and research
10 ties and partnerships with other countries.

11 (6) An analysis of the extent to which there is
12 collaboration, joint ventures, or partnerships be-
13 tween China and other foreign countries with respect
14 to semiconductor manufacturing.

15 (7) An analysis of the impact of United States
16 and allied and partner export controls on covered
17 items related to the development of semiconductor
18 manufacturing in China, specifically with respect to
19 the effectiveness of current United States protec-
20 tions against—

21 (A) export control workarounds and loop-
22 holes;

23 (B) circumvention through foreign invest-
24 ments or third-party acquisitions; and

1 (C) risks posed by collaborative agree-
2 ments, partnerships, supplier relocations, and
3 contractual relationships that may indirectly
4 benefit China.

5 (8) An assessment of whether such export con-
6 trols remain effective in curbing the development of
7 semiconductor manufacturing equipment capabilities
8 in China and recommendations for enhancing effec-
9 tiveness of such controls.

10 (9) An assessment of the implications of Chi-
11 nese semiconductor manufacturing dominance on—

12 (A) United States global competitiveness;

13 (B) United States national security and
14 national economic security; and

15 (C) the national economy of the United
16 States.

17 (c) FORM.—The report required by subsection (a)
18 shall be submitted in unclassified form and shall include
19 a classified annex, providing additional details and sup-
20 porting intelligence, as available. The unclassified portion,
21 or an unclassified synopsis, of the report shall concur-
22 rently be made available on a publicly available website
23 of the Federal Government and a notice to that effect shall
24 be concurrently published in the Federal Register.

○